In re the Application of: Yoshikazu TAKEDA et al.

Serial No.: Not yet Assigned

(§371 of international application No. PCT/JP2003/007577)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Filed: June 16, 2005

SEMICONDUCTOR MULTI-LAYERED STRUCTURE WITH NON-UNIFORM QUANTUM DOTS, AND LIGHT EMITTING DIODE, SEMICONDUCTOR LASER DIODE AND SEMICONDUCTOR LIGHT AMPLIFIER USING THE SAME AS WELL AS METHOD OF MAKING THEM

Attorney Docket Number: 052712

Customer Number: 38834

<u>INFORMATION</u> DISCLOSURE STATEMENT

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450

Date: June 16, 2005

Sir:

In compliance with 37 C.F.R. §1.56, Applicants direct the attention of the Patent and Trademark Office to the documents listed on the attached PTO/SB/08. A copy of each non-U.S. document is enclosed herewith.

In the event there are any fees due in connection with the filing of this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

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Enclosure: PTO/SB/08, 15 documents and international search report.

10/539635 pc'd PCT/PTO 16 JUN 2004

Complete if Known

New Application

Combined Form PTO/SB/08A&B

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

STAT	EMENT BY AP	PLICA	NT	Filing Date	June 16, 2005		
				First Named Inventor Yoshikazu TAKEDA			
(use	e as many sheets as r	necessary)		Art Unit			
•	·			Examiner Name			
Sheet	1	of	2	Attorney Docket Number	052712		

Application Number

Confirmation Number

	U.S. PATENT DOCUMENTS							
Examiner	Cite	Document Nun	nber	Publication Date				
Initials*	No.1	Number	Kind Code ² (if known)	MM-DD-YYYY	Name of Patentee or Applicant of Cited Document			
	1	US 2001/0028755 A1		10-11-2001	Tomoyuki AKIYAMA			

			F	DREIGN PA	TENT DOCUM	MENTS	
Examiner	Cite	Foreign Patent Document			Publication	Name of Patentee or	
Initials*	No.1	Country Code ³	Number ⁴	Kind Code ⁵ (if known)	Date MM-DD-YYYY	Applicant of Cited Document	Translation ⁶
	2	JР	2002-43696		02-08-2002	Fujitsu Ltd. (Cited in the Int'l. search Rpt)	Abstract
	3	JP	9-326506		12-16-1997	Fujitsu Ltd. (Cited in the Int'l. search Rpt)	Abstract
	4	JP	2001-255500		09-21-2001	Fujitsu Ltd. (Cited in the Int'l. search Rpt)	Abstract
	5	JР	2000-196065		07-14-2000	Fujitsu Ltd. (Cited in the Int'l. search Rpt)	Abstract
	6	JP	2000-340883		12-08-2000	Fujitsu Ltd. (Cited in the Specification)	Abstract

		NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation ⁶
_	7	Y. NONOGAKI et al.; "Formation of InGaAs dots on InP substrate with lattice-matching growth condition by droplet heteroepitaxy", Inst. Phys. Conf. Ser. No. 162, Chapter 9, 1999, pp.469-473. (Cited in the Int'l. search report).	Yes
	8	Y. ARAKAWA et al.; "Multidimensional quantum well laser and temperature dependence of its threshold current", Appl. Phys. Lett. Vol.40, No. 11, June 1, 1982, pp.939-941. (Cited in the Specification).	Yes
	9	M. ASADA et al.; "Gain and the Threshold of Three-Dimensional Quantum-Box Lasers", IEEE Journal of Quantum Electronics, Vol. QE-22, No. 9, Sept. 1986, pp. 1914-1921. (Cited in the Specification)	Yes
	10	K. J. VAHALA, "Quantum Box Fabrication Tolerance and Size Limits in Semiconductors and Their Effect on Optical Gain", IEEE, J. Quantum Electronics, Vol.24, No. 3, March 1988, pp.522-531. (Cited in the Specification)	Yes
	11	H. SAKAKI; "Quantum Wire Superlatices and Coupled Quantum Box Arrays: A Novel Method to Suppress Optical Phonon Scattering in Semiconductors", Jpn. J. Appl. Phys, Vol. 28, 1989, pp.L314-L316. (Cited in the Specification).	Yes
	12	N. KIRSTAEDTER et al.; "Low threshold, large T _o injection laser emission from (InGa) As quantum dots", Electronics letters, Vol. 30, No. 17, Aug. 18, 1994, pp.1416-1417. (Cited in the Specifiation).	
	13	Y. NONOGAKI et al.; "InAs dots grown on InP (001) by droplet hetero-epitaxi using OMVPE", Mat. Sci. & Eng., Vol. B51, 1998, pp.118-121. (Cited in the Specification).	Yes

Examiner Signature	 		Date Considered		

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹Applicant's unique citation designation number (optional). ²See Kind Codes of USPTO Patent Documents at www.uspto.gov, MPEP 901.04 or in the comment box of this document. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST. 3). ⁴For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to indicate here if English language Translation is attached.

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052712

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Attorney Docket Number

			U.S. I	PATENT DOCUM	MENTS
Examiner	Cite	Document I	Number	Publication Date	
Initials*	No.1	Number	Kind Code ² (if known)	MM-DD-YYYY	Name of Patentee or Applicant of Cited Document

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			F	OREIGN PA	TENT DOCUME	NTS	
Examiner	Cite	Cite Foreign I		ment	Publication	Name of Patentee or	
Initials*	No.1	Country Code ³	Number⁴	Kind Code ⁵ (if known)	Date MM-DD-YYYY	Applicant of Cited Document	Translation ⁶
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		NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation ⁶
	14	R. OGA et al.; "Room temperature electroluminescence at 1.55 μm from InAs quantum dots grown on (001) InP by droplet hetero-epitaxy); 10 th Int. Sump. Nanostructures: Physics and Technology, St. Petersburg, Russia, June 17-21, 2000.	Yes
	15	Woo-Sik LEE et al.; "Fabrication and Application of InAs quantum dots by droplet-hetero epitaxy on GaInAsP and AlInAs lattice-matched with InP substrate" The Institute of Electronics, Vol. 103, No. 47.	Abstract

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Examiner Signature	Date Considered
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